M em ory E ects in Electron Transport in Si Inversion Layers in the Dilute Regime: Individuality versus Universality

V.M.Pudalov^{a;b}, M.E.Gershenson^a, and H.Kojim a^a
^a Department of Physics and Astronomy, Rutgers University, New Jersey 08854, USA
^b P.N.Lebedev Physics Institute, 119991 Moscow, Russia

In order to separate the universal and sam ple-speci ce ects in the conductivity of high-m obility Si inversion layers, we studied the electron transport in the same device after cooling it down to $4\,\mathrm{K}$ at dierent xed values of the gate voltage V $^\mathrm{cool}$. Dierent V $^\mathrm{cool}$ did not modify signicantly either the momentum relaxation rate or the strength of electron-electron interactions. However, the temperature dependences of the resistance and the magnetoresistance in parallel magnetic elds, measured in the vicinity of the metal-insulator transition in 2D, carry a strong imprint of individuality of the quenched disorder determined by V $^\mathrm{cool}$. This demonstrates that the observed transition between \metallic" and insulating regimes involves both universale ects of electron-electron interaction and sample-specice ects. Far away from the transition, at lower carrier densities and lower resistivities $<0.1\mathrm{h}{=}\mathrm{e}^2$, the transport and magnetotransport become nearly universal.

A fter alm ost a decade of intensive research, the apparent metal-insulator transition (MII) in two-dimensional (2D) systems remains a rapidly evolving eld [1]. The central problem in this eld is whether the anomalous low-tem perature behavior of the conductivity, observed in high-m obility structures in the dilute lim it, signi es a novel quantum ground state in strongly-correlated system s, or this is a sem iclassical e ect of disorder on electron transport. Indeed, a great body of experimental data dem onstrates that, at least at su ciently large carrier densities (consequently, weak interactions), the lowtem perature behavior of disordered systems is governed by the universal quantum corrections to the conductivity [2]. On the other hand, there are also observations that near the apparent 2D M II, the behavior of dilute systems is very rich, and does not necessarily follow the sam e pattern (e. g., even for the sam e system, as Si MOSFETs, the "critical" resistance and the high-eld m agnetoresistance vary signi cantly for di erent sam ples [3,4]). This duality (universality versus individuality) is re ected in two approaches to the theoretical description of the "m etallic" regime: some models, based on strong electron-electron interactions, treat the transition as a universalphenom enon [5{10], whereas the others emphasize the role of a sam ple-speci c disorder (traps, localized spins, potential uctuations, etc.) [11{15].

In order to $\,$ nd a de nite experimental answer to this problem and to separate universal and non-universal (\individuality") e ects in the vicinity of the 2D M IT , we have studied the electron transport in the same SiM OS structure, which was slow by cooled down from room temperature to T = 4K at dierent xed values of the gate voltage $V_g = V^{\rm cool}$ [16]. Changing the cooling conditions allowed us to vary the conning potential and the density of quenched localized states without a ecting the main parameters which control electron-electron interactions in the system of mobile electrons: the momentum relaxation rate and the interaction constants. By tuning V_g at low temperatures, we varied the electron density nover

the range n = (0.7 3) 10^1 cm 2 in a system with a snapshot disorder pattern. Two key features of the 2D M IT, strong dependences of the resistivity on the temperature and parallel magnetic eld, have been studied.

We have observed two distinct regimes as a function of the electron density. At relatively high densities (resis- $0:1h=e^2$), the dependences R (T) and R (B_k) in weak parallelm agnetic elds B k are sim ilar for di erent cooldowns; the sim ilarity indicates 'universal' behavior. In contrast, at low densities ((0:11)h=e), or in m oderate and strong parallel elds $g B_k$ E_{F} $k_B T$, the cooling conditions a ect dram atically the electron transport. This observation provides direct experim entalevidence that the behavior of dilute system s becom es sam ple-speci c near the apparent 2D M II nom atter how one approaches the transition (either by decreasing the electron density, or by increasing the parallel magnetic

The resistivity measurements were performed on a high mobility SiM O SFET sample [17] at the bath temperatures 0:05 1:2K. The crossed magnetic eld system allowed to accurately align the magnetic eld parallel to the plane of the 2DEG [18]. The carrier density, found from the period of Shubnikov-de Haas (SdH) oscillations, varies linearly with $V_g\colon n$ C (Vy Vth), where C (= 1:103 $10^{11}\,/\text{V}\,\text{cm}^{\,2}$ for the studied sample) is determined by the oxide thickness. The 'threshold' voltage V_{th} varied little (within 0.15V) for dierent cool-downs and remained xed as long as the sample was maintained at low temperatures (up to a few months).

Figure 1 shows the mobility versus V $_{\rm g}$ for ve dierent cooldowns with V $^{\rm cool}=$ 0;5;10;18, and 25V. The peak mobility for dierent cooldowns varies by less than

7%); this demonstrates that the momentum relaxation time is not strongly a ected by the cooling conditions. We also observed that the amplitudes of the SdH oscillations are similar for dierent cool-downs, as shown in the inset to Fig. 1. These two observations are consistent with each other, since the quantum lifetime q is nearly

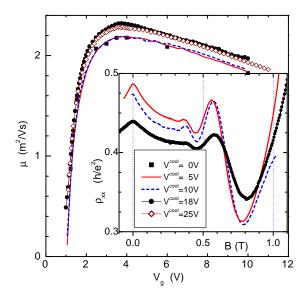


FIG. 1. The mobility versus the gate voltage for different cool-downs. The V $^{\rm cool}$ values for both the main panel and the inset are shown in the gure. Examples of the SdH oscillations, shown in the inset for the same V $_{\rm g}$ = 1:15 V , T = 0:1 K , B $_{\rm k}$ = 0:03 T , demonstrate that the quantum time $_{\rm q}$ is not very sensitive to the cooling conditions. The carrier densities are (from top to bottom) n = 1:081, 1:092, 1:070 in units $10^{11}\,{\rm cm}^{-2}$.

Figure 2a shows the dependences (T) for two cooldowns in the vicinity of the 2D MII. Far from the $h=e^2$, the dependences (T) are transition, where cooldown-independent. However, in the vicinity of the transition (h=e²), a dram atically di erent behavior is observed. The irreproducibility of (T) for dierent cool-downs is clearly seen for the curves in Fig. 2 which correspond to the same at the lowest T: these curves, being di erent at higher tem peratures, converge with decreasing T. The sample-speciem emory elects vanish also at su ciently low temperatures: this suggests that the underlying mechanism is related to the nitetem perature e ects in a system which retains a quenched disorder. These results suggest that, in addition to universal e ects, a nite-tem perature and sam ple-specic m echanism, which strongly a ects the resistivity, comes into play.

The 'critical' density n_c , which corresponds to the transition, was found from a linear extrapolation to zero of the density dependence of the activation energy (n) in the insulating regime (T) / exp(=T) [3,19]. The dependences (T), which corresponded to $n=n_c$ for two cool-downs shown in Fig. 2a, are highlighted in bold. It is clear that (i) the 'critical' densities and 'critical' resistivities depend on the cooling conditions, and (ii) the 'critical' dependences (T; $n=n_c$) are non-monotonic (see also Refs. [19,20]). Observation of the non-monotonic

critical dependences $_{\rm c}$ (T) suggests that a) saturation of the tem perature dependences at n = $\rm n_{\rm c}$, reported in [21], is not a universale ect, and b) the critical density is not necessarily associated with the sign change of d =dT (n) [19].

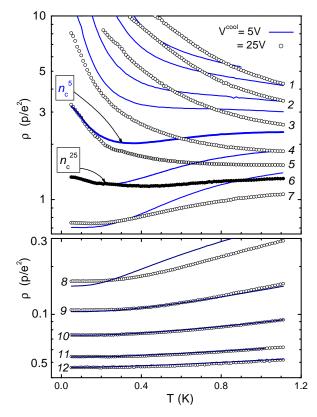


FIG .2. Tem perature dependences of the resistivity for two di erent cool-downs. The densities, which correspond to curves 1 to 12, are as follow: 0.783, 0.827, 0.882, 0.942, 0.972, 1.001, 1.021, 1.31, 1.53, 1.87, 2.29, 2.58 in unites of 10^{11} cm $^{-2}$.

We now turn to the magnetoresistance (MR) in parallel elds; the data are shown in Figs. 3 and 4. This MR is usually associated with the spin e ects [1,4]. In the theoretical models of the parallel—eld MR, based on electron-electron interactions, the MR is controlled by the electron electron and the momentum relaxation time [5,10,22]. An important advantage of our method is that cooling of the same sample at dierent V cool does not a ect these parameters. Thus, one might expect to observe a sample—independent behavior if the MR is controlled solely by the universal interaction elects.

Firstly, let us consider the range of elds much weaker than the eld of complete spin polarization (g $_B$ B $_k$ E $_F$). The insets to Figs. 3a and 3b show that the M R is proportional to B $_k^2$ at g $_B$ B $_k$ =k $_B$ T 1. We found that the slope d =dB 2 is nearly cooldown-independent (i.e. universal) only for the densities n > 1:3 $_10^{11}$ cm 2 (which are by 30% greater than the critical density $_{\rm n_c}$),

or for the resistivities < 0:16h= e^2 (com pare insets to Figs. 3a and 3b). With approaching n_c , this universality vanishes: Figure 3a shows that even when the zero-eld resistivity is as small as $0.22h=e^2$, the slope varies by a factor of 1.3 for dierent V cool .

For the interm ediate elds, $k_B\,T < g_{B\,B\,k} < E_F$, the (B_k) behavior is not universal over the whole density range $n=(1-3)-1\dot\theta^1$ cm 2 (Figs. 3a,b). As n decreases and approaches n_c , the cooldown-dependent variations of R (B_k) increase progressively. Observation of large (-50%) non-universal variations of the M R at interm ediate elds makes the scaling analysis [23] of the M R in this eld range dubious.

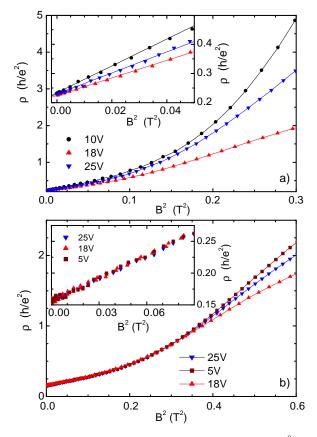


FIG. 3. Examples of the dependences (B_k^2) at $T=0.3\,\mathrm{K}$ for the carrier density (a) $1.20-10^{11}$ cm 2 and (b) $1.34-10^{11}$ cm 2 . The insets blow up the low-eld region of the quadratic behavior. The values of V $^{\mathrm{cool}}$ are indicated for each curve.

The in vence of cooldown conditions becomes even more dramatic in strong elds, B > $E_F = g_B$. Despite the fact that the dependences (n) for dierent cooldowns are very similar (Fig. 1), we observed very large variations in the strong-eld MR. Figures 4a and 4b show R(B_k) for dierent cooldowns at two values of n. The cooldown conditions cause factor-of-ve changes in (B) in high elds and factor-of-two changes in the values of $B_k = B_{sat}$ at which the MR 'saturates' at a given carrier density. The latter quantity was determined from

the intercept of the tangents at elds below and above M R saturation [4].

Figure 4c shows the dependences B_{sat} (n) for dierent cool-downs. We also plotted here the density dependence of the eld $B_{pol} = 2E_F = g_B = n h^2 = m g_B$, for the complete spin polarization of mobile electrons (m is the renormalized e ective mass). The dependence B_{pol}(n) was calculated using sample-independent (universal) g m values [18]. C om parison between B sat and B_{pol} shows that B_{sat} does not necessarily manifest the com plete spin polarization, and that the coincidence of B_{sat} with B_{pol} reported in Ref. [24] may be rather accidental. This non-universal, sample-dependent behavior ofB_{sat} agrees with earlier observations made on dierent sam ples [4]. We em phasize that the curves for dierent V cool (in each of Figs. 4 a and b) correspond to the sam e density, as follows from Hall voltage and/or SdH oscillations m easurem ents. The fact that B sat is a cooldowndependent parameter, suggests that the MR in strong parallel elds is not solely related to spin-polarization of mobile electrons; we speculate that it also re ects the spin polarization of the sam ple-speci c localized electron states, which might have the e ective q-factor quite different from that for the mobile electrons [4].

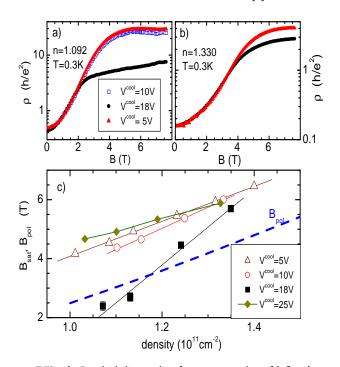


FIG. 4. Resistivity vs in-plane magnetic eld for three cool-downs at two densities: a) n = 1:092 $10^{11}\,\text{cm}^{-2}$ and b) n = 1:33 $10^{11}\,\text{cm}^{-2}$. c) The saturation eld B sat versus n for four di erent cool-downs. Solid lines are guides to the eye. D ashed line shows the eld of complete spin polarization calculated on the basis of direct measurements of the spin susceptibility for mobile electrons [18].

It is worth mentioning that the in uence of vari-

able disorder on transport and m agnetotransport in Si-M O SFETs has been observed earlier. Both the temperature dependence (T) and m agnetoresistance (B $_{\rm k}$) were found to be dierent in samples with dierent mobility [3,4] and in samples cooled down with dierent values of substrate bias voltage [25]. In these studies, however, the sample mobility was changed signicantly. In contrast, in our studies we kept constant the sample mobility and all parameters relevant to electron-electron interaction.

To sum marize, by cooling the same high-mobility Si- $M \cap S$ sample from room temperature down to T = 4K at di erent xed values of the gate voltage, we tested universality of the temperature and magnetic-eld dependences of the resistivity near the 2D M II . An important advantage of this approach is that the dierent cooldown procedures do not a ect the param eters which control the contribution of the interaction e ects to the resistivity. It has been found that in the vicinity of the transih=e2), the sam ple-specice ects strongly a ect tion ((T); these e ects vanish only when decreases below 0:1h=e2 with increasing electron density. Non-universal behavior has been also observed for the magnetoresistance in parallel magnetic elds. The e ect is especially dram atic in moderate (E $_{\rm F}$ > g $_{\rm B}$ B > T) and strong $(g B B > E_F)$ elds: it extends to much higher electron densities (we observed pronounced non-universality of R (B_k) over a wide range n = (1) 3) 10^{1} cm 2). Our results clearly demonstrate that the apparent metalinsulator transition in 2D involves both universal and sam ple-specice ects. These results also help to establish the borderline between the regimes where the electron transport in high-mobility SiMOS-structures is either universal or sam ple-specic. Understanding of the non-universal regim e requires detailed know ledge of the interface disorder at low tem peratures.

A uthors acknow ledge fruitful discussions with E . A braham s, B . L . A ltshuler and D . L . M aslov.

The work was partially supported by the NSF, INTAS, NATO, NWO, and Russian Programs RFBR, Statistical physics', Integration', and The State support of the leading scientic schools'.

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